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Sep 25, 2013 Materials Science and Engineering by an Acid/Base Two-Step Processing Procedure, Chemistry of Materials, Souvik Banerjee, Richard F. Reidy, and Laura B. Rothman, Cryogenic Aerosols and Supercritical Fluid Cleaning, Handbook of Semiconductor Wafer Cleaning Technology, 2nd edition, Editors:

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RCA clean - Wikipedia, the free encyclopedia -

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1 CURRICULUM VITAE Richard F. Reidy III Department -

Developed a science and technology-based curriculum and schedule (8 hours of instruction .. Foams, Society for the Advancement of Material and Process Engineering, ed. . Supercritical Fluid Cleaning, Handbook of Semiconductor Wafer Cleaning Technology, 2nd edition, Editors: Werner Kern, Karen Reinhardt, 2007.

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Improve the laser damage resistance of fused -

Jul 9, 2013 SPIE 8786, Pacific Rim Laser Damage 2013: Optical Materials for chemical surface cleaning and optimized HF-based etch process. of optical glass", Applied Surface Science 253, 4951-4954 (2007) Karen A. Reinhardt, Werner Kern, "Handbook of silicon wafer cleaning technology 2nd edition", ISBN

Ultraviolet - ozone cleaning of semiconductor -

Science, Technology, 234 Handbook of Semiconductor Wafer Cleaning Technology To study the variables of the UV cleaning procedure, Vig and LeBus .. angle surface, because human skin oils contain materials, such as inorganic.

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Aug 31, 2008 9780815515548 Handbook of silicon wafer cleaning technology, 2d ed. Ed. by Karen Reinhardt and Werner Kern. William Andrew Publishing

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Sep 5, 2011 The temperature of the Si clean surface preparation, the final Reinhardt KA, Kern W, (Eds): Handbook of silicon wafer cleaning technology.

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